

surface science

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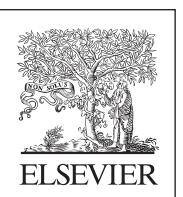
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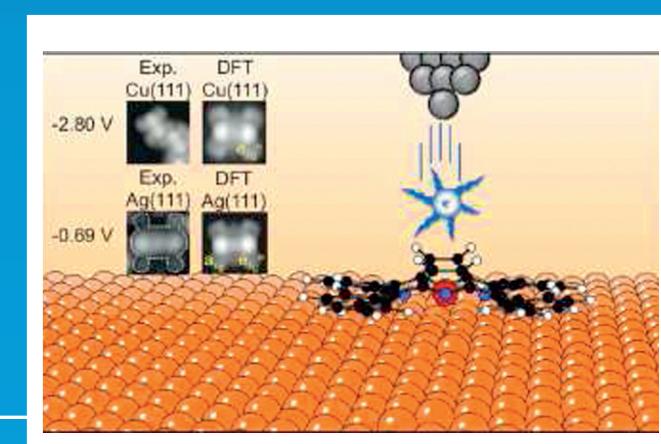
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- reactivity of surfaces as related to various applied areas including heterogeneous catalysis, chemistry at electrified interfaces, and semiconductors functionalization
- phenomena at interfaces relevant to energy storage and conversion, and fuels production and utilization
- surface reactivity for environmental protection and pollution remediation
- interactions at surfaces of soft matter, including polymers and biomaterials.

Both experimental and theoretical work, including modeling, is within the scope of the journal. Work published in Surface Science reaches a wide readership, from chemistry and physics to biology and materials science and engineering, providing an excellent forum for cross-fertilization of ideas and broad dissemination of scientific discoveries.

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